Status of XFEL/SPring-8 Construction

Tsumoru Shintake

as representing Joint XFEL/SPring-8 Construction Team

R&D Technical Director XFEL/SPring-8 Chief Scientist RIKEN SPring-8 Center

SPring-8 Operating ten years

XFEL/SPring-8 Building construction completed March 2009

12 2 2 4

SCSS Test Accelerator Since 2006, EVU user facility











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Experimental hall

Dec. 2009





Accelerator installation









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Testing Modulator & Klystron



Welcome to Laboratory Tour on Saturday SPring-8 Ticket available till this evening.



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Undulator Line



Status of XFEL/SPring-8 Construction

	FY'06	FY'07	FY'08	FY'09	FY'10	FY'11
Building	-				AC'10	
Accelerating structures	ED Production					
and waveguide systems					ion	
Klystrons and modulators	Klystro	n ◀━━━━━	Producti	on		
	Мо	dulator <		Install	ation	
Control cabinets and low level rf systems			Produ	iction		
				Instal		eam
Undulators				Productio	n	ray B
						t
Beam Commissioning		Hi	gh power	rf proces	sing →	Firs
			Beam	Commis	sioning <	→

SCSS : SPring-8 Compact SASE Source



Why Thermionic Cathode?

based on perception on technology

Established Technology on Single Crystal Cathode for Electron Microscope, LaB6 or CeB6

■high quality crystal available from shelf.
■long life > 10,000 hs
■strong against contamination → easy handling.
■very stable emission at > 30 A/cm²



High power klystron beam dynamics

- $\blacksquare \rightarrow$ stable velocity bunching,
- but 100 times or more!
- \blacksquare \rightarrow SCSS Test Accelerator, proved emittance preservation.

IX-band LC R&D \rightarrow 500 kV pulse gun for klystron.

Use Small Size Cathode



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CeB6 Thermionic Electron Gun K. Togawa

Cathode Assembly

Heated Cathode in Stem







The gun voltage=500 kV Temperature was measured at the sleeve by a radiation monitor.

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Operational Experience of 500 kV Gun

■Applying 500 kV pulse.

■3 micro-sec pulse driven by klystron modulator.

Gun sits inside HV pulse tank, filled with oil.





No HV breakdown at 500 kV for 4 years, daily operation.

Measured Emittance at the Gun

Beam Profile



Beam energy	500 keV
Peak current	1 A
Pulse width (FWHM)	3 µs
Repetition rate	10 Hz
Normalized emittance (rms, 100% electrons)	1.1π mm mrad
Normalized emittance (rms, 90% electrons)	0.6π mm mrad

Phase Space Profile

Test Accelerator Configuration



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SCSS Test Accelerator Performance

238 MHz

buncher

In-vacuum

undulator

C-band

E-beam

1.8 m x 4

S-band

buncher

476 MHz

booster

accelerator

Charge: 0.3 nC

Emax = 37 MV/m

Two 4.5 m long.

Energy = 250 MeV

In-Vacuum Undulators

Period = 15 mm, K=1.3

Emittance: 0.7 π.mm.mrad

(measured at undulator)

Four C-band accelerators

500 kV Pulse electron gun CeB6 Thermionic cathode Beam current 1 Amp.

2006 First lasing at 49 nm

2008 User operation stat

2007 Full saturation at 60 nm

CeB₆ Thermionic Gun provides stable beam.

Beam Profile CCD Image Scale 10 mm



250 MeV Compressor

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Undulator Input

Undulator Output

The normalized emittance is estimated to be $0.7\pi mm.mrad$



Timing Jitter



SCSS Test Accelerator User Run Has been Started in 2008

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50~60 nm, 30 μJ/pulse Multi-photon absorption Coherent diffraction imaging etc.



2008/01/28 *First experience, but team did nice work.*



We replaced CeB6 crystal in SCSS accelerator, after 20,000 hour operation.





Anode flange had color change.





contamination (lowered electron emission).

XFEL/SPring-8 Building construction completed March 2009

Experimental Hall (under construction)

Undulator Hall

1.10

400 m Accelerator Tunnel

Klystron Gallery

Machine Assembly Hall

Beam Acceleration and Compression



RF Acceleration System in XFEL/SPring-8



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C-band R&D

C-band Klystron Development

Under life test since April 1999



Traveling-wave output structure

Solenoid Focus (4.6kW)

1.5 μΡ

Dispenser Cathode (D74.5mm,6.3A/cm²)

53 MW, 2.5 µsec, 50 pps, 47%



TOSHIBA E3746 No.3

0.5 µs/div
Mass Production of Klystrons at TOSHIBA

- 64 C-band klystron
- 4 S-band klystron
- 1 L-band klystron

C-band Klystron 5712 MHz, 50 MW 4 μsec, 60 pps 45 % efficiency Three-cell traveling wave output



C-band System Configuration



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C-band is High Gradient (35 MV/m, max 40 MV/m)

- Modulator + Control Cabinet have to fit within 3.9 m each. → Need to make "Compact Modulator"
- High packing efficiency = Active Length/ Actual Length =(1791 x 8) / (15462+806) = 0.88



Single Tank Modulator (PFN circuit + Transformer)



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At the R&D, Ship Engine Make at AIOI contributed.



Suitable for mass-production.

Compact Modulator for 50 MW Klystrons

- Compact 1 m x 1.2 m x 1.7 m,
- Very low noise (<10 Vpp on 200 V heater line)</p>
- Water cooled. Max surface temp 45 deg at max-operation.





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Modulator Mass Production at NICHICON



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Modulator Tank Fabrication



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Modulators are Arriving to XFEL/SPring-8



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All modulator are tested at high power at 50 kV, 60 pps, 8 hour before installation.



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EOL Diode Failure Problem

Summer 2009



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Cause was wrong connection of ground line.



HV breakdown on klystron gun. Shockwave jumps over the transformer windings, with capacitive coupling. Frequency is to high ~100 MHz, shockwave runs ground line on PFN. It reflects back at EOL side as open end, creates standing wave. EOL diode turns ON very short time, then voltage reverses quickly. Before the carrier extinction time, voltage reverses, and charge remains in depletion region with high field. Charge is accelerated and hit anode!

First Modulator was Installed.

Summer 2009



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May 2010

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Highly Stable Inverter Type PFN Charger for stable operation of XFEL.



Highly stable PFN charger < 100 PPMp-p High power capacitor charging system.

- 1.8 Apeak at 50 kV
- Pulse to Pulse < 100 ppm.pp</p>
- Main Switching at 20 kHz, IGBT
- Sub switiching at 80 kHz, FET



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When voltage approaches to target, sub-inverter controls the voltage in fine mode.



Achieved PFN Charging voltage stability
80 ppm (peak-peak) for 1 minute
190 ppm (peak-peak) for 8 hours.

Otake's Team: LLRF, Beam Diagnostics



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MADOCA Controls, LLRF, Temp Feedback, PFN Charger



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Beam Monitor Devices

BPM Calibration

By Y. Otake team.



OTR Screen Monitor

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C-band Accelerator for Multi-bunch Option



T. Shintake, "Choke Mode Cavity", Jpn. J. Appl. Phys. Vol. 31 pp. L1567-L1570, November 1

Higher Order Mode Damping for Multi-bunch operation. Maximum 50 bunches x 1 nC, at 4.2 nsec spacing

X-ray 4.2 nsec x 50 bunches will be key for Single bio-molecule imaging to improve Luminosity.



13,000 cells are under mass production.



Sadao Miura, MITSUBISHI Heavy Ind, April 20

HITACHI Cable Co. completed mass production of C-band cell. June 2009





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Mass Production of C-band Accelerator at MITSUBISHI Heavy Ind. 2007 ~ 2009

Laser Guided Precision Machining



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L'AR

Brazing of C-band Accelerators



•A number of technical improvements have been made.

•1~2 columns per week.

Mass-production of 128 tubes of the C-band Accelerating Structure for 8 GeV linac. @ MITSUBISHI Heavy Ind.

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MITSUBISHI-Team completed 100 tubes (out of 128) C-band Accelerator. Photo March 2009



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Routinely Operation: C-band High Gradient Test

T. Sakurai, IPAC2010 19-inch rack **RF Pulse Compressor** Control system Low-Level RF Timing system Beam Dump Faraday Cup) **Compact Modulator Pulse** klystron C-band Accelerating structure

Fig.2 Birds'eve view of the test bunker.

- Sample test from mass production.
- C-band 1 unit for one month.
- 35 MV/m is routinely achieved. (Very low trip rate.)
- Processing up to 40 MV/m, 60 pps.

RF Pulse Compressor $Q_0 :> 180000, \beta :> 8.0$ Two TE0,1,15 cavities **RF power Gain : (typ.) 3**

Installed C-band Accelerator

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C-band Accelerator

Pulse Compressor Gain x3

Choke Mode Structure 35 MV/m x 1.8 m

A Marine

Choke Mode Structure 35 MV/m x 1.8 m

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F

In Vacuum Undulator





Undulator for XFEL/SPring-8

Undulator Type		In-Vacuum Planer Undulator
Active Length		5 m
Undulator Period		18 mm
Magnetic Circuit		Hybrid (NdFeB+Permendur)
Peak Field	Maximum	1.31 T
	Nominal	1.13 T
К	Maximum	2.2
	Nominal	1.9
Gap	Minimum	3.5 mm
	Nominal	4.5 mm
Maximum Attractive Force		~ 6 ton

Undulator for XFEL/SPring-8

The undulator for XFEL is made by the team guided by H. Kitamura and T. Tanaka

Outlook of 5 m long in-vacuum undulator for X-ray FEL.

NeFeB magnet array, undulator period is 18 mm.

Expected Performance of XFEL/SPring-8



Schedule

2010 Sept. Complete installation.

2010 Oct. ~ 2011 Feb. High power processing.

2011 March First beam to the undulator.

2011 April - July Beam commissioning, and the first FEL Lasing?

Summary

- CeB6 thermionic performance was fully investigated, and found to be matched to XFEL/SPring-8.
- Various new hardware components have been developed in this laboratory, LLRF, single-tank klystron modulator, high precision power supply, etc.
 - Those components will be useful to other accelerator projects including FELs, light source injectors and also ERLs.
- We will contribute to accomplish X-ray lasing of XFEL/SPring-8, expected Summer 2010.
- This laboratory will keep activity for future upgrade of XFEL/SPring-8.

Acknowledgement

- We would like to acknowledge to all of colleague here and also from outside for their various help and encouragements to our laboratory.
- We wish thank to people from industries for their collaborative efforts on development of all hardware components.
- We would like to say thank to people at secretaries office in this institute, and director office.

Installed Modulator in XFEL Klystron Gallery



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C-band R&D Summary @ 2000

C-band	Kly stron	RF Pulse	Accelerating
Kly stron	Modulator	Compressor	Structure
50 MW, _O K	110 MW _O K	Flat Pulse	1.8 m _{OK}
2.5 sec, 47 %	100 pps	Gain 3.3	Choke-Mode
Life test >5000 hour, OK.	Smart modulator using inverter HV charger. Runnin g for klystron life tes t.	Three-cell cavity.	Beam accelera tion at 50 MV/m was done at ATF-KEK, with S-band model. HOM damping perfor mance was proved by ASSET- SLAC test, 1998.

Contribution to XFEL Construction

Bunch Compression after the Gun

Maintain bunch-length on the electron rest-fram being constant.



Mitsubishi Heavy Ind. made Accelerating Tubes



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C-band System Configuration



Installed modulator in the klystron gallery, WG connections.



April, 2010

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C-band R&D Team at KEK (1996~2000)



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Remained Troubles

Feb. 2010: We found some of film capacitors were breakdown in February this year. Resonant charging circuit uses 200 pieces of 1.5 kV, 1 uF capacitor. Case is identified to be a side effect due to vacuum oil sintering process of HV circuit and un-balanced voltage distributions in series connection